ABSTRACT

In this paper, we demonstrate quality factor ($Q$) enhancement of a silicon RF MEMS resonator by cryogenic cooling from room temperature down to liquid nitrogen temperatures (78K). The resulting $Q$ is approximately 63,000 at a frequency of 3.72 GHz, yielding an $fQ$ product of $2.34 \times 10^{14}$ Hz. This work verifies that the resonator is operating in the Landau-Rumer regime at room temperature, where individual phonon scattering results in a strong dependence of $Q$ on temperature [1-3]. We find that as the temperature approaches 120K, the $Q$ converges to a constant value, indicating that intrinsic phonon loss mechanisms are replaced by temperature independent electrical and mechanical anchor losses as the dominant $Q$ limiting factor.

INTRODUCTION

Advances in micromechanical resonators have resulted in high quality factor ($Q$) resonators at room temperature with frequencies in the microwave regime, highlighting the possibility of their use in integrated RF systems [4, 5]. Theoretical and experimental studies hypothesize that phonon interactions dominate the intrinsic loss in bulk-mode resonators, making possible even higher $Q$ at lower temperatures [1-3, 6-12]. Chip-scale micro-cryogenic cooling is not as farfetched as it seems, as integrated microsystems demonstrating cooling to temperatures as low as 76K have already been developed [13]. Recent measurements of $Q$ in 60-MHz silicon resonators demonstrated $Q \propto 1/T$, characteristic of the Akhiezer effect [7-9]. Instead, if we operate at frequencies in the Landau-Rumer regime, $Q \propto 1/T^4$, greatly enhancing the gains in $Q$ due to cooling. We have previously demonstrated a pn-diode transduced, low motional impedance resonator (Fig. 1) at 3.72 GHz, which is operated in the Landau-Rumer regime [14]. This transduction mechanism is used primarily because it allows for efficient transduction at high frequencies in a completely homogeneous resonator, allowing us to carefully study the intrinsic loss mechanisms due to phonon scattering.

EXPERIMENTAL RESULTS AND DISCUSSION

An acoustic wave in a resonator can be thought of as a highly excited acoustic phonon mode containing a number of phonons much larger than the thermal equilibrium value. Due to various scattering processes, phonons in this highly excited mode will decay into other modes, resulting in attenuation of the acoustic wave. The dominant phonon-phonon scattering mechanisms depend strongly on the relationship between $\omega$, the frequency of the acoustic wave, and the thermal phonon lifetime $\tau_{th}$. When $\omega \tau_{th} \ll 1$, the device is in the Akhiezer regime and when $\omega \tau_{th} \gg 1$, the Landau-Rumer effect

Table 1: Expressions estimating $Q$ limits due to the two main phonon-phonon scattering mechanisms [1-3, 7-9]

<table>
<thead>
<tr>
<th>Effect</th>
<th>Expression</th>
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<tbody>
<tr>
<td>Akhiezer Effect</td>
<td>$Q_{Akh} = \frac{2\pi \rho c_D^2}{c_v \gamma^2} \frac{1 + (\omega \tau_{th})^2}{\omega \tau_{th}} \frac{1}{\theta T}$</td>
</tr>
<tr>
<td>Landau-Rumer Effect</td>
<td>$Q_{LR} = \frac{30 \rho c_v^4 \gamma^3}{\pi \gamma k_B^2} \frac{1}{\theta T^3}$</td>
</tr>
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\( \rho = \) density, \( \gamma = \) Grüneisen parameter, \( c_v = \) longitudinal velocity, \( \kappa = \) thermal conductivity, \( c_D = \) Debye velocity, \( h = \) Planck’s constant, \( k_B = \) volumetric heat capacity

Figure 1. (a) Top-view SEM of the pn-diode transduced 3.7-GHz silicon micromechanical resonator and ANSYS simulation of thickness-stretch (FBAR) mode (inset) [14] (b) resonator cross sectional diagram

Figure 2. Measured $Q$ of pn-diode transduced silicon resonator showing $1/T^4$ dependence at temperatures close to 300K. The $Q$ eventually tapers off to a constant value at around 120K to a maximum of about 63,000. We believe this is due to anchor losses and routing resistance. All measurements are performed in a Lakeshore vacuum RF probe station.

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temperature due to the strong dependence of $Q$ on frequency. A near $1/T^4$ dependence is seen throughout the measured temperature range indicating operation in the Landau-Rumer regime.

must be considered. Acoustic attenuation in both regimes has been studied extensively and theoretical details can be found in the literature [1-3, 7-9]. Expressions for the quality factor in these regimes are shown in Table 1.

Interestingly, it has been shown that for resonators operating in the Landau-Rumer regime, $Q$ is constant with frequency, a fact which is exploited in the high frequency resonators used in this work [14]. Operation in this regime is beneficial not only in terms of $f-Q$ product scaling with frequency ($f-Q \propto f$), but also with temperature due to the strong dependence of $Q \propto 1/T^4$, as shown in Eq. (2). Fig. 2 verifies that our device is in this regime by showing such dependence at temperatures close to 300K. However, the $Q$ approaches a constant value as temperature decreases, which we believe to be a result of both electrical and mechanical losses due to the anchor. Electrical resistive losses, which typically are not considered in electrostatically transduced resonators, are important because of the low motional impedance of these devices.

In order to verify whether the remaining loss is due to the Landau-Rumer effect, we lumped the $Q$ obtained in the constant-$Q$ region into an equivalent anchor loss term $Q_{anchor}$ and, assuming that the remaining loss is entirely intrinsic, used the relationship

$$\frac{1}{Q_{total}} = \frac{1}{Q_{anchor}} + \frac{1}{Q_{intrinsic}}$$

(3)

to determine $Q_{intrinsic}$ plotted in Fig. 3. This plot shows a $1/T^4$ dependence, thus verifying operation in the Landau-Rumer regime. Note that these experiments were repeated with three other similar resonators, all showing similar temperature dependence.

CONCLUSION

Through this work, we were able to verify operation of the pn-diode transduced micromechanical resonators in the Landau-Rumer regime. We have demonstrated the $1/T^4$ dependence of $Q$ and exploited it to demonstrate $Q \sim 63,000$ and $fQ$ product of $2.34 \times 10^{14}$ Hz at 78K. The conclusions drawn from this work are not dependent on the use of pn-diode transduction and are widely applicable to GHz frequency single crystal silicon resonators. With the availability of chip-scale spot cooling, silicon micromechanical resonators show the potential to be used in high-$Q$ applications such as chip-scale spectrum analysis and narrowband RF applications.

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REFERENCES


CONTACT:
E. Hwang, tel: +1-408-515-4132; eoh3@cornell.edu